

Form PTO-1449 (REV. 8-83)		US Dept. of Commerce PATENT & TRADEMARK OFFICE		ATTY DOCKET NO. 118336		APPLICATION NO. New U.S. Application	
INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)				APPLICANT(S) Atsushi TAKAKUWA et al.			
				FILING DATE January 14, 2004		GROUP	
U.S. PATENT DOCUMENTS							
EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	
Loke	1.	6,057,067	5/2/2000	ISBERG et al.			
FOREIGN PATENT DOCUMENTS							
		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS	
Loke	2.	JP A 2003-31778 w/abstract & transl.	1/31/2003	JAPAN			
Loke	3.	JP A 2003-142666 w/abstract & transl.	5/16/2003	JAPAN			
Loke	4.	JP A 2000-133809 w/abstract & transl.	5/12/2000	JAPAN			
Loke	5.	JP A 2001-51296 w/abstract & transl.	2/23/2001	JAPAN			
Loke	6.	JP A 2001-125138 w/abstract & transl.	5/11/2001	JAPAN			
Loke	7.	JP A 2002-217390 w/abstract & transl.	8/2/2002	JAPAN			
Loke	8.	JP A 2002-217391 w/abstract & transl.	8/2/2002	JAPAN			
Loke	9.	JP A 10-125929 w/abstract & transl.	5/15/1998	JAPAN			
Loke	10.	JP A 10-125930 w/abstract & transl.	5/15/1998	JAPAN			
Loke	11.	JP A 10-125931 w/abstract & transl.	5/15/1998	JAPAN			
Loke	12.	JP A 11-26733 w/abstract & transl.	1/29/1999	JAPAN			
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)							
Loke	13.	Tatsuya Shimoda et al.; "Surface Free Technology by Laser Annealing (SUFTLA)"; IEDM; 1999; pp 289-292					

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Loke	14.	Sumio UTSUNOMIYA et al.; "Low-Temperature poly-Si TFT transferred onto plastic substrates by using surface free technology by laser ablation/annealing (SUFTLA); Journal of the SID; 2002; pp 69-73
Loke	15.	S. Utsunomiya et al.; "Low Temperature Poly-Si TFT-LCD Transferred onto Plastic Substrate Using Surface Free Technology by Laser Ablation/Annealing (SUFTLA); Asia Display/IDW; 2001; pp 339-342
Loke	16.	Sumio Utsunomiya et al.; "4-3: Flexible TFT-LEPD Transferred onto Plastic Substrate Using Surface Free Technology by Laser Ablation/Annealing (SUFTLA)"; EURODISPLAY; 2002; pp 79-82
Loke	17.	Akihiko ASANO et al.; "43.2: Low-Temperature Polycrystalline-Silicon TFT Color LCD Panel Made of Plastic Substrates"; SID 02 DIGEST; 2002; pp 1196-1199
Loke	18.	M. Kimura et al.; "An area-ratio gray-scale method to achieve image uniformity in TFT-LEPDs"; Journal of SID; 2000; pp 93-97
Loke	19.	T. Shimoda et al.; " Technology for Active Matrix Light Emitting Polymer Displays"; IEDM; 1999; pp 107-110
Loke	20.	Sumio Utsunomiya et al.; "21.3: Flexible Color AM-OLED Display Fabricated Using Surface Free Technology by Laser Ablation/Annealing (SUFTLA) and Ink-jet Printing Technology" SID 03 DIGEST; 2003; pp 864-867
EXAMINER		Loke
		DATE CONSIDERED 6/12/05
Examiner: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.		